

ABSTRACT OF THE DISCLOSURE

A color selection mask is provided with an aperture region including a slit region (21) and bridge regions (22). The bridge regions (22) are provided on top and
5 bottom ends of the aperture region. In the slit region (21), slits (123) through which electron beams pass and strips (124) are arranged alternately. The strips (124) extend into the bridge regions (22), where bridges (25) for connecting adjacent two of the strips (124) and through holes (122) through which electron beams pass are provided.